Development of Laser Processing System with Two Color Pyrometer

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DEVELOPMENT OF LASER PROCESSING SYSTEM WITH TWO COLOR PYROMETER

Research Project

Research Abstract

Project/Area Number
10555246
Research Category
Grant-in-Aid for Scientific Research (B)
Allocation Type
Single-year Grants
Section
展開研究
Research Field
Material processing/treatments
Research Institution
Kanazawa University
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Project Period (FY)
1998 – 1999
Keywords
LASER PROCESSING / PRECISION MACHINING / TWO-COLOR PYROMETER / FIBER COUPLER / INFRARED RADIATION PYROMETER / BREAKING / LASER FORMING

The objective of the present study is to establish a laser machining system for micro machining in a high precision. The temperature of workpiece irradiated with laser is measured accurately using a new type of infrared radiation pyrometer with an optical fiber. The main results obtained in this study are summarized as follows:

- 1. A basic technique for measuring temperature of workpiece irradiated with laser is established.
- 2. A technique for controlling crack progress direction in breaking of silicon wafer is established. And by measuring AE signal, we can monitor the crack progress on the wafer.
- 3. The relationship between the temperature of workpiece irradiated with the deformation angle in forming of stainless plate is determined. Consequently, we can control the deformation by monitoring the temperature.
- 4. Breaking of micro-diamond grindstone and liquid-crystal glass, and forming of lead frame of semiconductor cell, are become the subjects for future study.

Research Products (12 results)

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